

Analysis and Design of Analog Integrated Circuits
Lecture 14

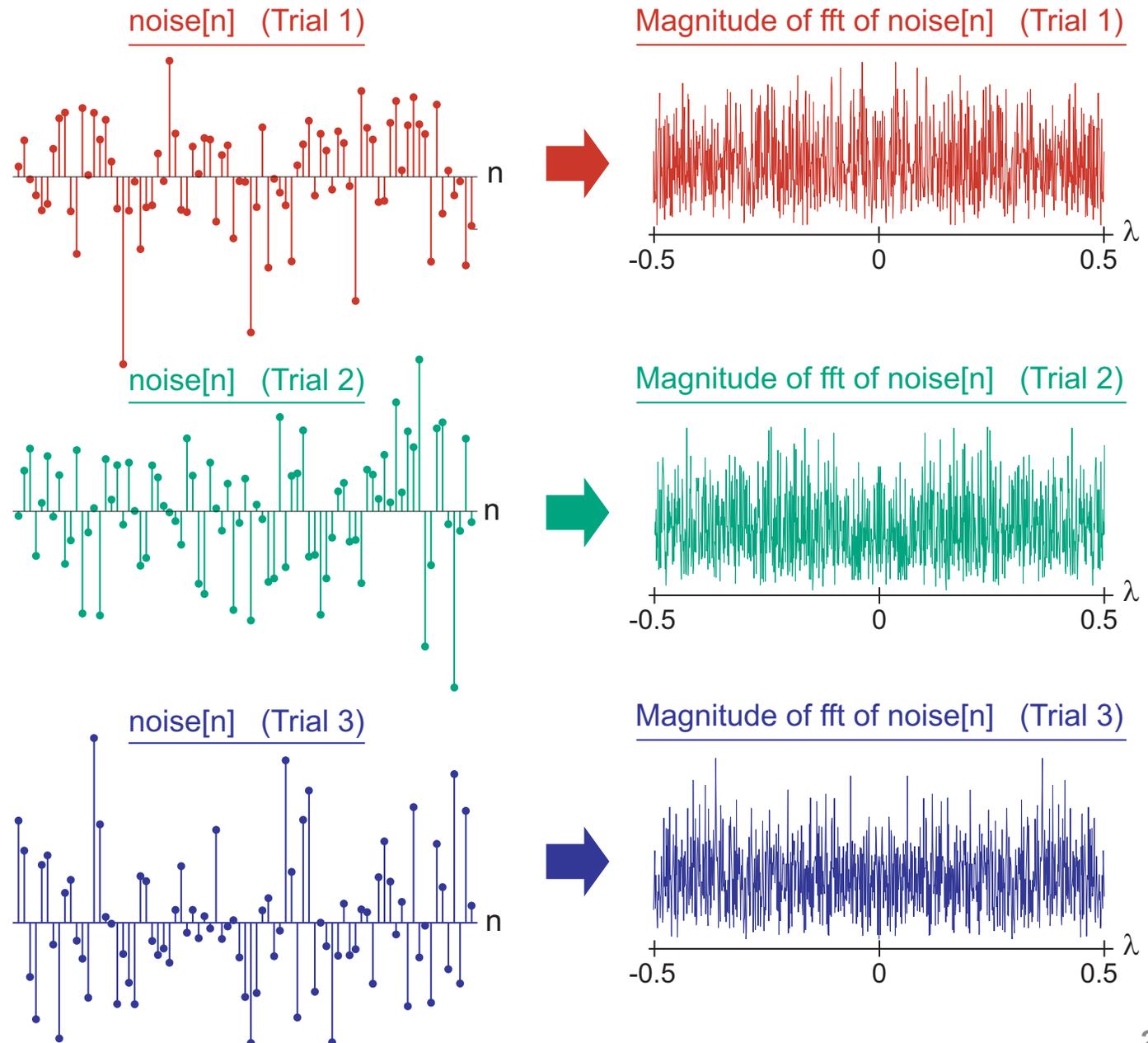
Noise Spectral Analysis for Circuit Elements

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Recall Frequency Domain View of Random Process

- It is valid to take the *FFT* of a sequence from a given trial
- However, notice that the *FFT* result changes across trials
 - Fourier Transform of a random process is undefined !
 - We need a new tool called spectral analysis



Expectation of a Random Variable

- The *expectation* of random variable y is defined as

$$E(y) = \int_{-\infty}^{\infty} y f_y(y) dy$$

- We see that:

$$E(y) = \int_{-\infty}^{\infty} y f_y(y) dy = \mu_y$$

$$E((y - \mu_y)^2) = \int_{-\infty}^{\infty} (y - \mu_y)^2 f_y(y) dy = \sigma_y^2$$

- In the case where $\mu_y = 0$ (i.e., the mean of y is 0)

$$E(y^2) = E((y - \mu_y)^2) = \sigma_y^2$$

- $E(y^2)$ is called the second moment of random variable y

Independence of Random Variables

- Consider two random variables x and y
 - x and y are said to be independent if and only if

$$f(x, y) = f(x)f(y)$$

- Where $f(x,y)$ is the joint probability distribution of x and y
- which implies

$$E(xy) = \int_{-\infty}^{\infty} \int_{-\infty}^{\infty} xy f(x, y) dx dy = \int_{-\infty}^{\infty} x f(x) dx \int_{-\infty}^{\infty} y f(y) dy$$

$$\Rightarrow E(xy) = E(x)E(y)$$

- The above relationship is also true under a less strict condition called *linear independence*
 - If x and y are zero mean, then $E(xy) = 0$ implies that x and y are *uncorrelated*

Autocorrelation and Spectral Density (Discrete-Time)

- Assume a zero mean, stationary random process $x[n]$:
 - The autocorrelation of $x[n]$ is defined as:

$$R_{xx}[m] = E(x[n] \cdot x[n + m])$$

- Note that:

$$R_{xx}[0] = E(x^2[n]) = \sigma_x^2$$

- The power spectral density of random process $x[n]$ is defined as

$$S_x(\lambda) = \sum_{m=-\infty}^{\infty} R_{xx}[m] e^{-j2\pi\lambda m}$$

- Note that $\lambda = fT$, where f is frequency (in Hz) and T is the sample period of the process (in units of seconds)
- Power spectral density of $x[n]$ is essentially the (Discrete-Time) Fourier Transform of the autocorrelation of $x[n]$

Implications of Independence (Discrete-Time)

- If the samples of a zero mean random process, $x[n]$, are independent of each other, this implies

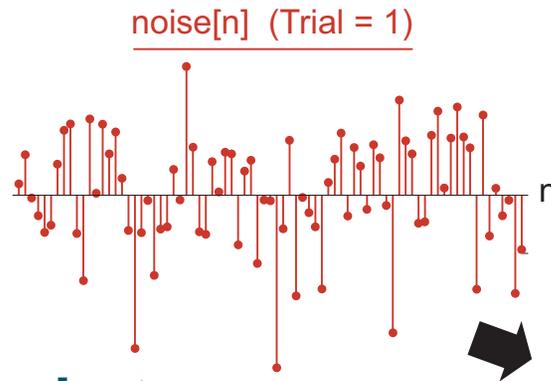
$$\begin{aligned} R_{xx}[m] &= E(x[n]x[n+m]) \\ &= \begin{cases} E(x^2[n]) = \sigma_x^2, & m = 0 \\ E(x[n])E(x[n+m]) = 0, & m \neq 0 \end{cases} \end{aligned}$$

- The corresponding power spectral density is then calculated as

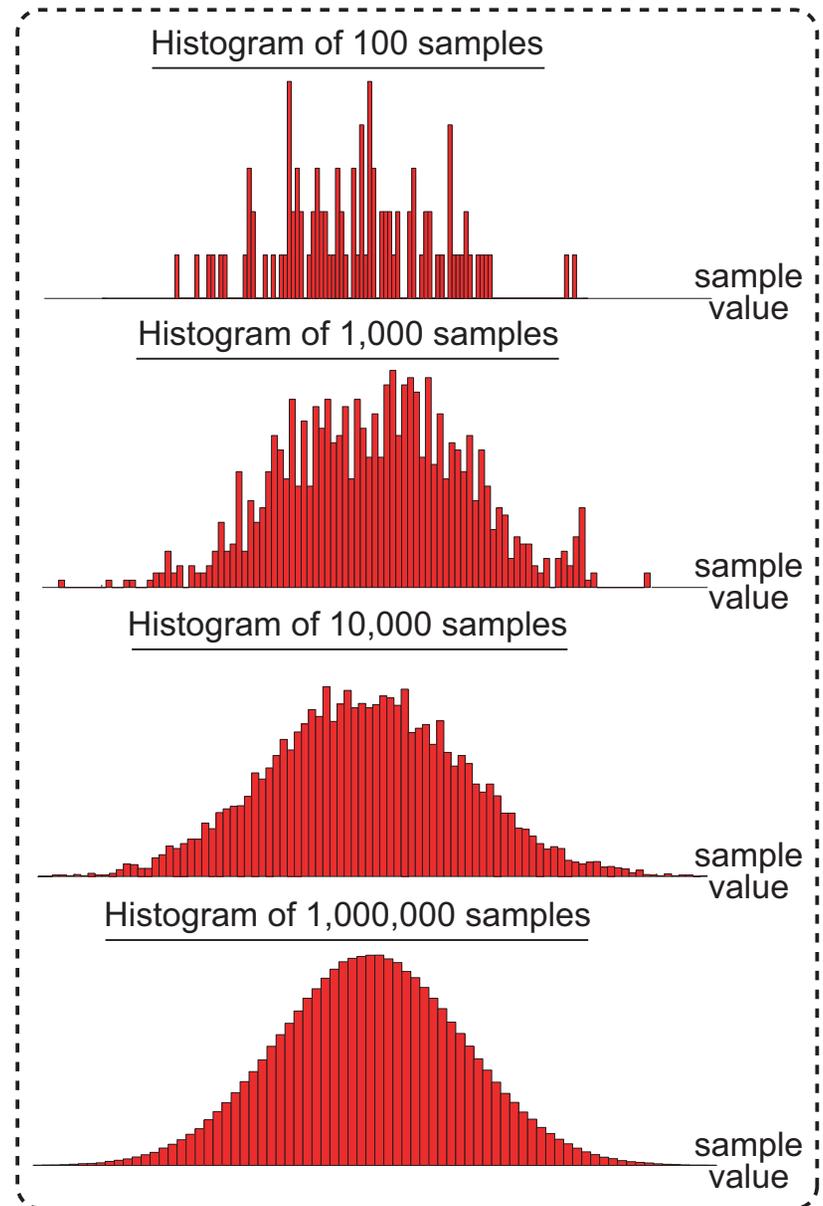
$$\Rightarrow S_x(\lambda) = \sum_{m=-\infty}^{\infty} R_{xx}[m]e^{-j2\pi\lambda m} = \sigma_x^2$$

- This is known as a *white* random process, whose spectral density is flat across all frequencies

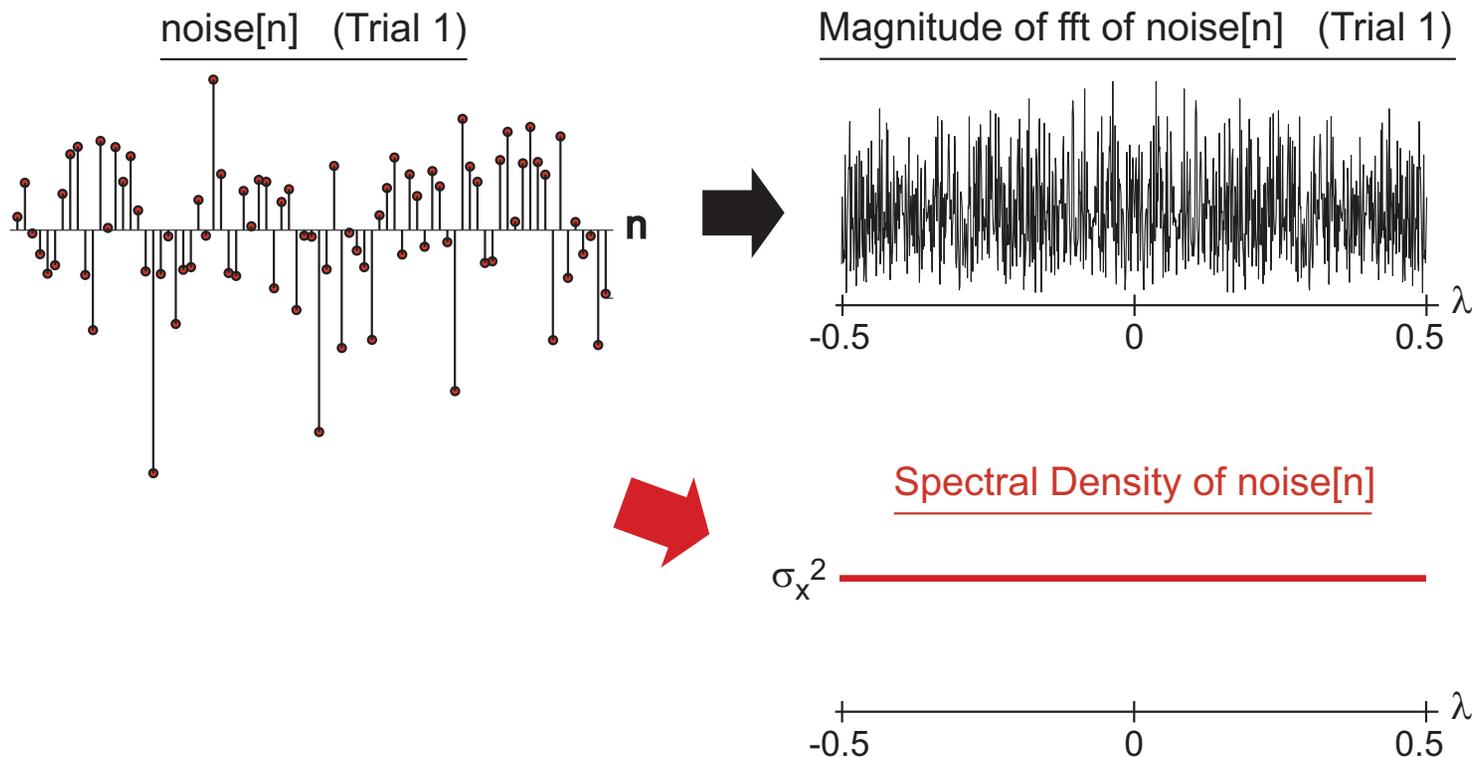
Understanding White Random Processes



- Independence between samples implies that previous samples provide no benefit in trying to predict the value of the current sample
- For Gaussian white processes, the best we can do is use the Gaussian PDF to determine the probability of a sample being within a given range
 - Variance of the process is a key parameter



Spectral Density of a White Process (Discrete-Time)



- **The spectral density of a white process is well defined**
 - This is in contrast to the FFT of a white process, which varies between different trials of the process
 - Note that the spectral density is *double-sided* since it is based on the Fourier Transform (which is defined for both positive and negative frequencies)

Autocorrelation and Spectral Density (Continuous-Time)

- Assume a zero mean, stationary random process $x(t)$:
 - The autocorrelation of $x(t)$ is defined as:

$$R_{xx}(\tau) = E(x(t) \cdot x(t + \tau))$$

- Note that

$$R_{xx}(0) = E(x^2(t)) = \sigma_x^2$$

- The power spectral density of random process $x(t)$ is defined as

$$S_x(f) = \int_{\tau=-\infty}^{\infty} R_{xx}(\tau) e^{-j2\pi f\tau} d\tau$$

- Again, the power spectral density corresponds to the Fourier Transform of the autocorrelation function of the random process $x(t)$

White Random Process (Continuous-Time)

- Assume a zero mean, stationary random process $x(t)$:
 - Assuming that the samples of a random process, $x(t)$, are independent of each other, this implies

$$R_{xx}(\tau) = E(x(t)x(t + \tau)) = N_o\delta(t)$$

- Where $\delta(t)$ is known as the delta function with properties:

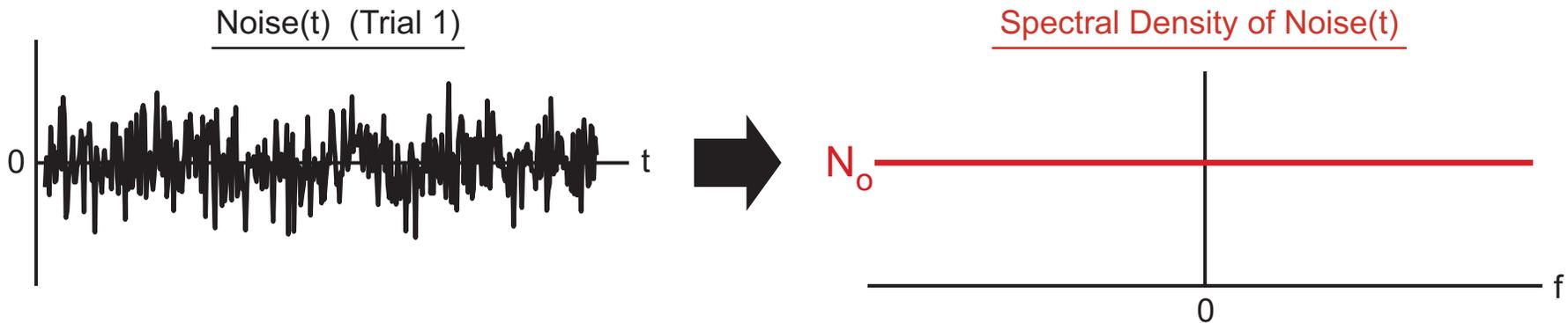
$$\delta(t) = 0 \text{ for } t \neq 0, \quad \int_{-\infty}^{\infty} \delta(t)dt = 1$$

- The power spectral density of $x(t)$ is then:

$$S_x(f) = \int_{\tau=-\infty}^{\infty} R_{xx}(\tau)e^{-j2\pi f\tau} d\tau = N_o$$

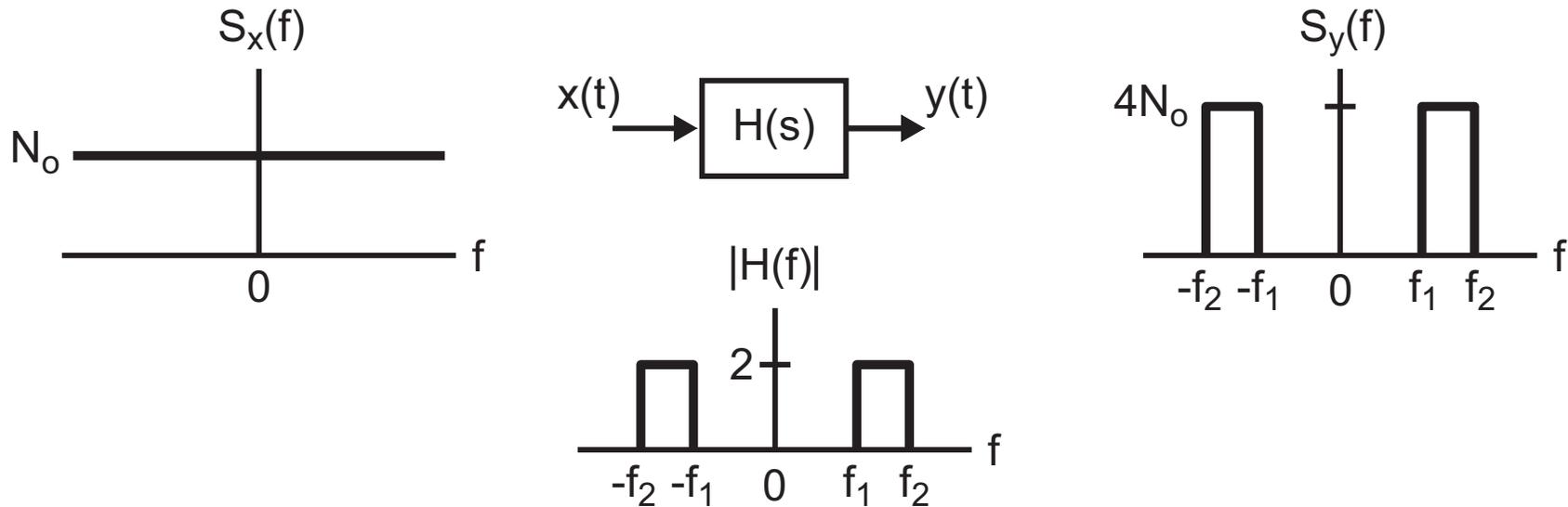
- As with a discrete-time white process, a continuous-time white process has flat spectral density across all frequencies
- Note that the variance of a white process is actually infinite
 - Practical “white noise” is bandlimited and has finite variance

Spectral Density of a White Process (Continuous-Time)



- As with a discrete-time, white process, the spectral density of a continuous-time, white process is well defined
 - It is flat with frequency
 - For analog circuits, units of N_0 are V^2/Hz or A^2/Hz
 - It is double-sided, meaning that it is defined for both positive and negative frequencies

Spectral Density Calculations Involving Filtering

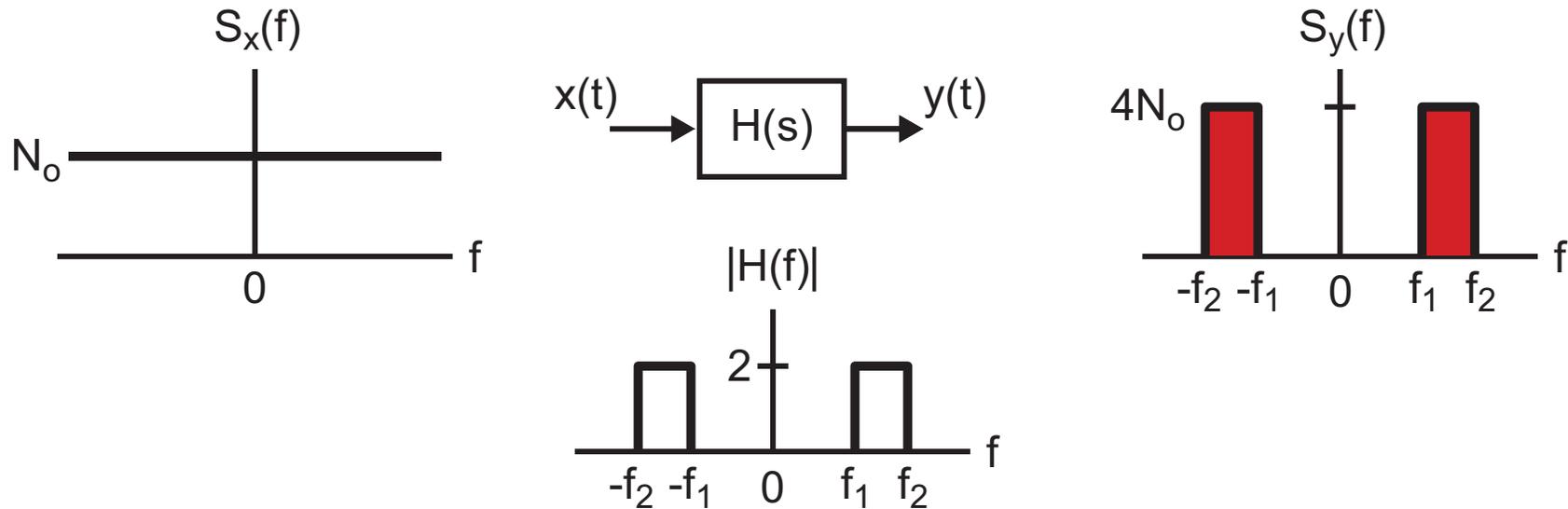


- Assuming an input random process $x(t)$ is fed into a linear, time-invariant filter $H(s)$, the resulting power spectral density of the output random process $y(t)$ is calculated as:

$$S_y(f) = |H(f)|^2 S_x(f)$$

- Note that filtering a white random process leads to a new random process that is no longer white
 - The output spectral density is no longer flat across frequency
 - Different output samples in time are no longer independent

Spectral Density Calculations Involving Power



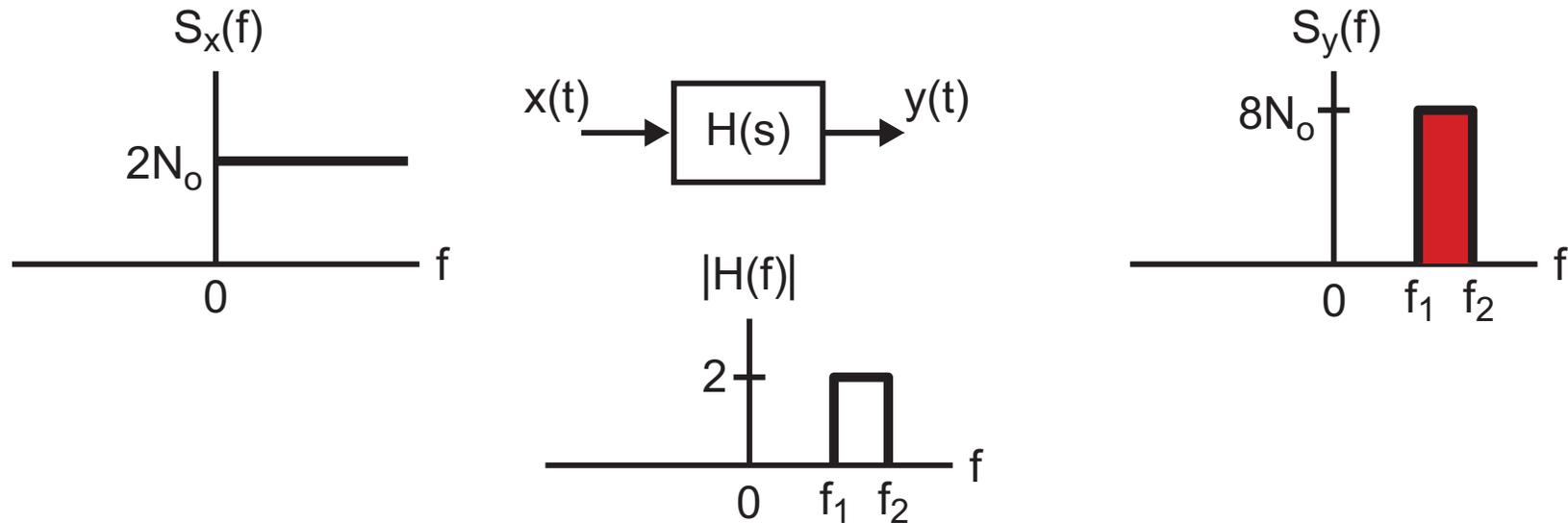
- The power (i.e., variance) of a zero mean random process corresponds to the integration of its power spectral density

$$P_y = \sigma_y^2 = R_{yy}(0) = \int_{-\infty}^{\infty} S_y(f) df = \int_{-f_2}^{-f_1} S_y(f) + \int_{f_1}^{f_2} S_y(f)$$

- Note that we can consider the power in certain frequency bands by changing the value of f_1 and f_2
- In the above example:

$$P_y = 4N_o \cdot 2(f_2 - f_1)$$

Double-Sided Versus Single-Sided Spectral Densities

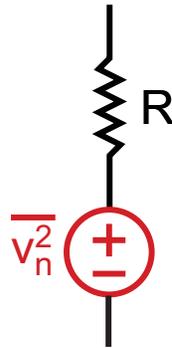


- It turns out that power spectral densities are always symmetric about positive and negative frequencies
- Single-sided spectral densities offer a short cut in which only the positive frequencies are drawn
 - In order to conserve power, the spectral density magnitude is doubled
 - For the above example: $\Rightarrow P_y = 8N_0 \cdot (f_2 - f_1)$

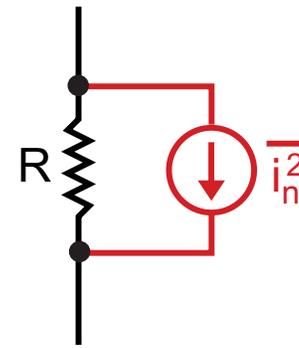
We will use only single-sided spectral densities in this class

Noise in Resistors

- Corresponds to white noise (i.e., thermal noise) in terms of either voltage or current



$$\overline{v_n^2} = 4kTR\Delta f$$

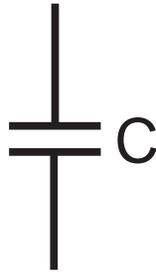


$$\overline{i_n^2} = 4kT\frac{1}{R}\Delta f$$

- Circuit designers like to use the above notation in which $\overline{v_n^2}$ and $\overline{i_n^2}$ represent power in a given bandwidth Δf in units of Volts² or Amps², respectively
- k is Boltzmann's constant: $k = 1.38 \times 10^{-23} \text{ J/K}$
- T is temperature (in Kelvins)
 - Usually assume room temperature of 27 degrees Celsius
 $\Rightarrow T = 300\text{K}$

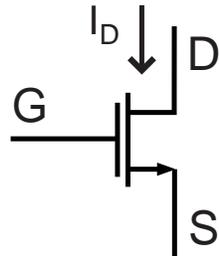
Noise In Inductors and Capacitors

- **Ideal capacitors and inductors have no noise!**



- **In practice, however, they will have parasitic resistance**
 - **Induces noise**
 - **Parameterized by adding resistances in parallel/series with inductor/capacitor**
 - **Include parasitic resistor noise sources**

Noise in CMOS Transistors (Assumed in Saturation)



Transistor Noise Sources

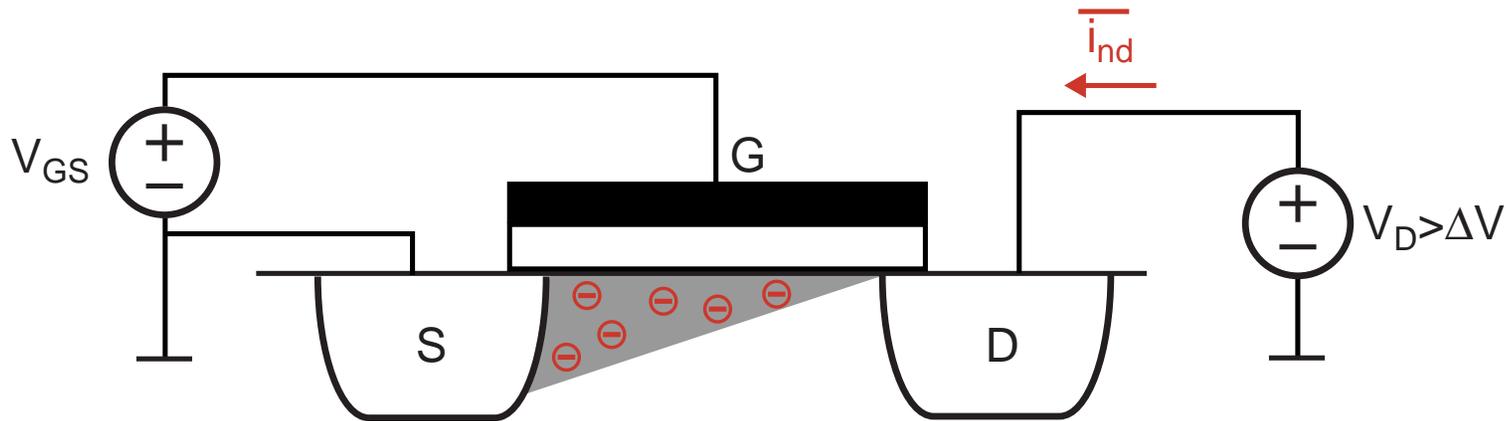
Drain Noise (Thermal and 1/f)

Gate Noise (Induced and Routing Parasitic)

- **Modeling of noise in transistors includes several noise sources**
 - **Drain noise**
 - Thermal and 1/f – influenced by transistor size and bias
 - **Gate noise**
 - Induced from channel – influenced by transistor size and bias
 - Caused by routing resistance to gate (including resistance of polysilicon gate)
 - Can be made negligible with proper layout such as fingering of devices

We will ignore gate noise in this class

Drain Noise – Thermal (Assume Device in Saturation)



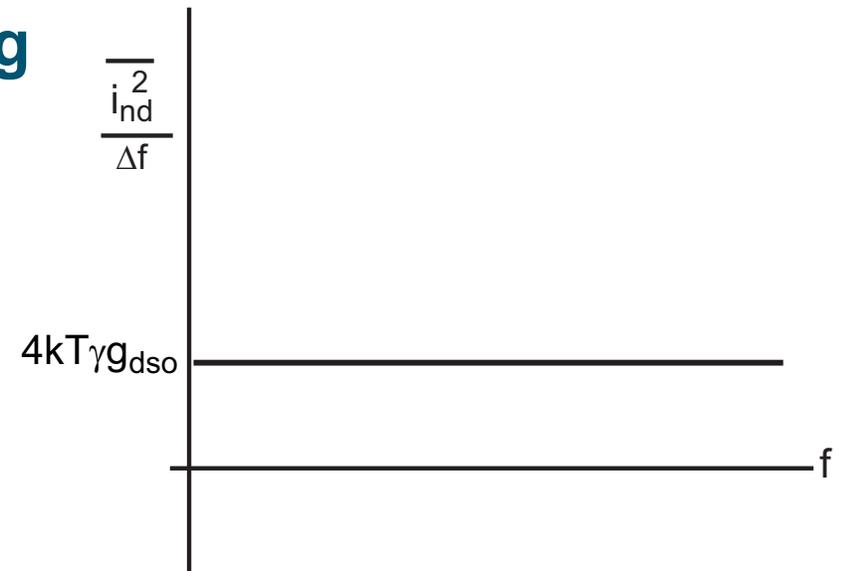
- Thermally agitated carriers in the channel cause a randomly varying current

$$\overline{i_{nd}^2} \Big|_{th} = 4kT\gamma g_{dso} \Delta f$$

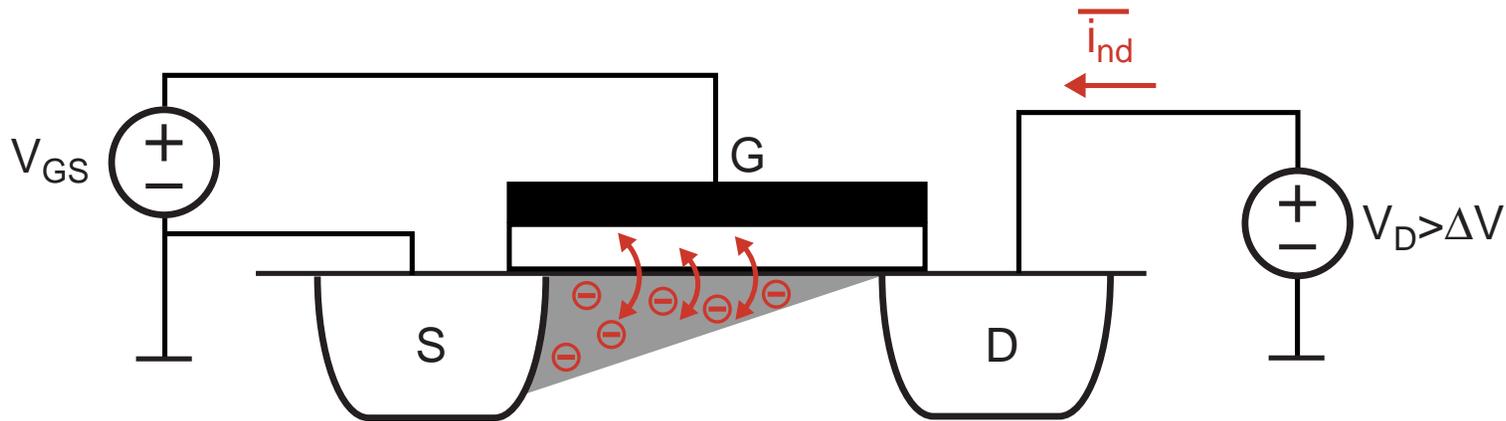
- γ is called excess noise factor

- $\gamma = 2/3$ in long channel
- $\gamma = 2$ to 3 (or higher!) in short channel MOS devices

- g_{dso} will be discussed shortly (Note: $g_{dso} = g_m / \alpha$)



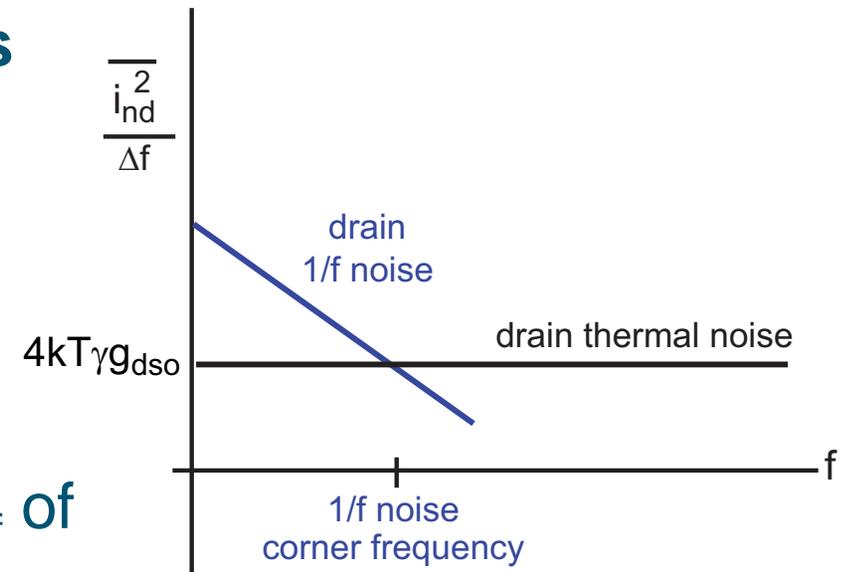
Drain Noise – 1/f (Assume Device in Saturation)



- **Traps at channel/oxide interface randomly capture/release carriers**

$$\overline{i_{nd}^2} \Big|_{1/f} \approx \frac{K_f}{f} \frac{g_m^2}{WLC_{ox}^2} \Delta f$$

- Parameterized by K_f
 - K_f provided by fab
 - Sometimes K_f of PMOS \ll K_f of NMOS due to buried channel
- **To minimize: want large area (high WL)**



Drain-Source Conductance: g_{dso}

- g_{dso} is defined as channel resistance with $V_{ds}=0$

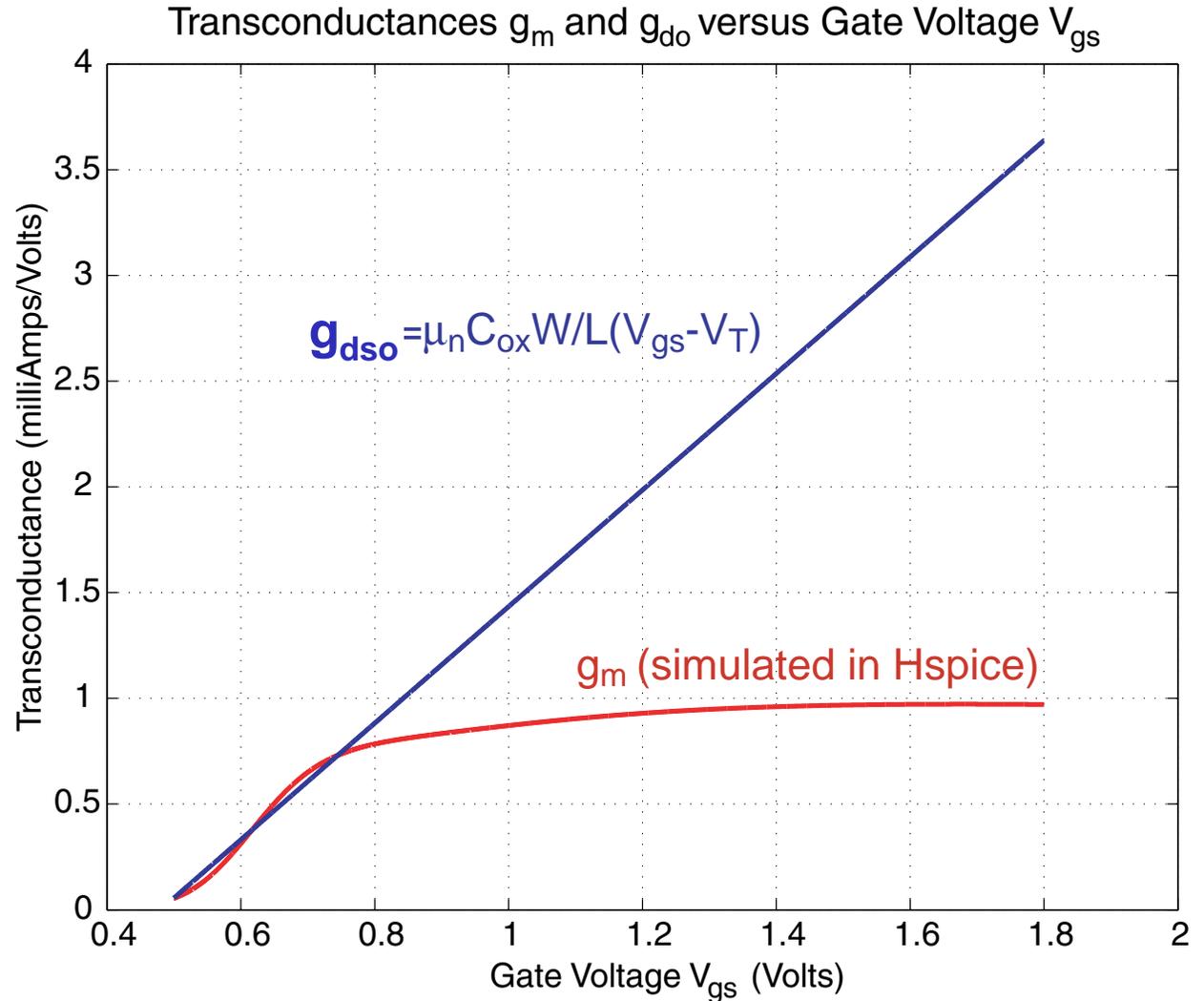
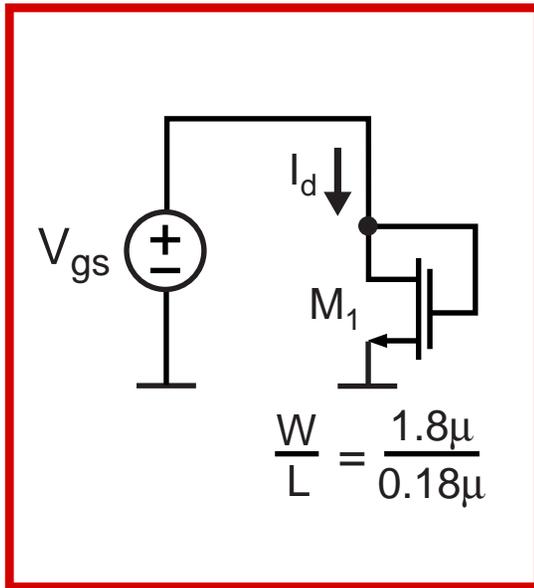
- Transistor in triode, so that

$$I_d = \mu_n C_{ox} \frac{W}{L} \left((V_{gs} - V_T) V_{ds} - \frac{V_{ds}^2}{2} \right)$$

$$\Rightarrow g_{dso} = \left. \frac{dI_d}{dV_{ds}} \right|_{V_{ds}=0} = \mu_n C_{ox} \frac{W}{L} (V_{gs} - V_T)$$

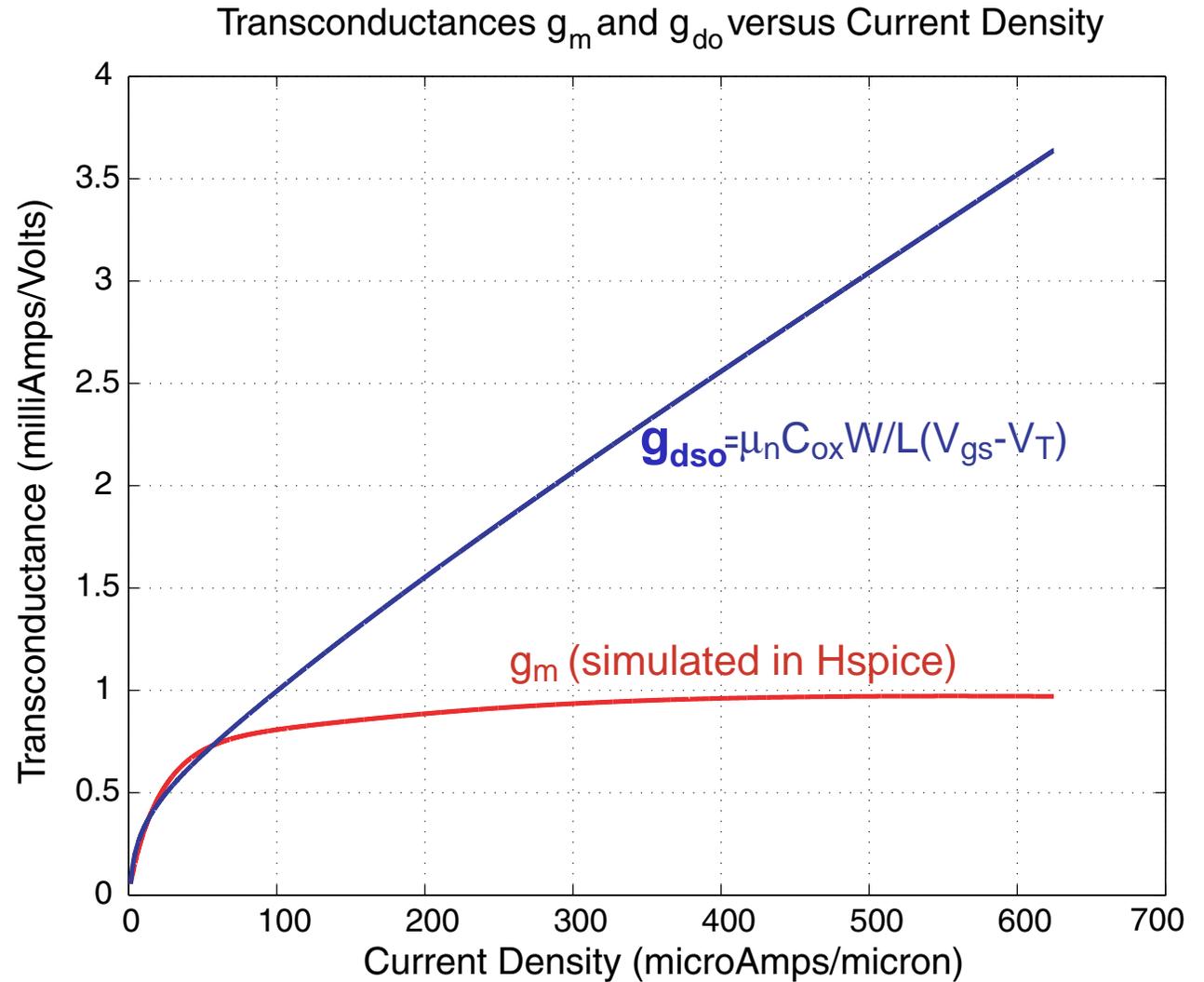
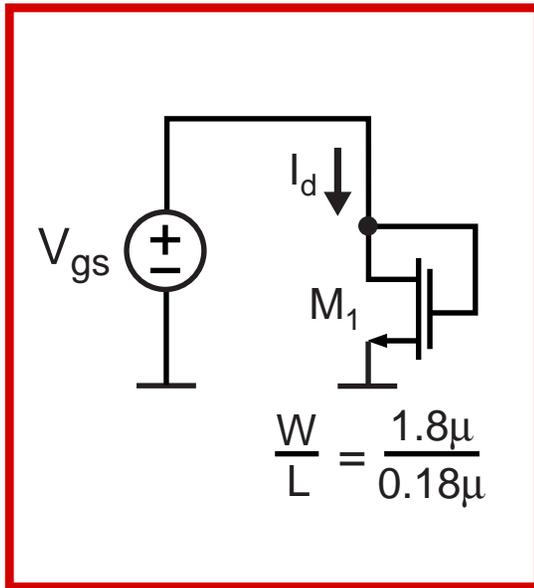
- Ideally equals g_m , but effects such as velocity saturation can cause g_{dso} to be different than g_m

Plot of g_m and g_{dso} versus V_{gs} for 0.18μ NMOS Device

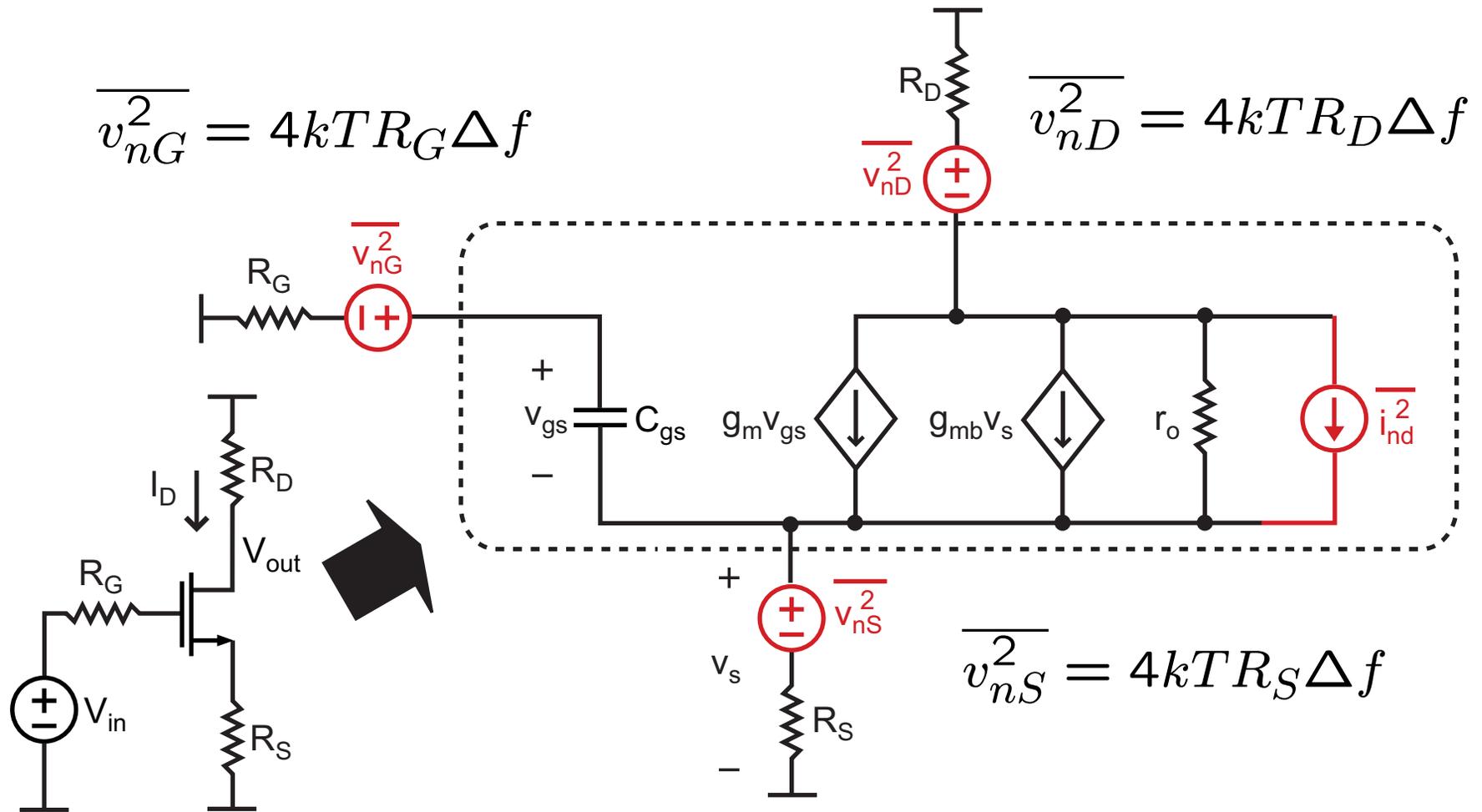


- For V_{gs} bias voltages around 1.2 V: $\alpha = \frac{g_m}{g_{dso}} \approx \frac{1}{2}$

Plot of g_m and g_{dso} versus I_{dens} for 0.18μ NMOS Device



Key Noise Sources for Noise Analysis



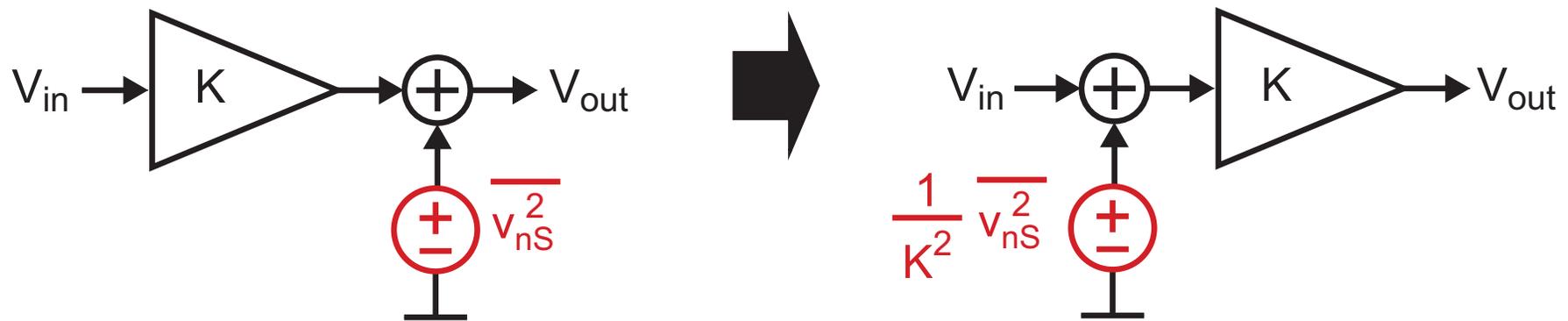
- Transistor drain noise:**

$$\overline{i_{nd}^2} = \underbrace{4kT\gamma g_{dso}\Delta f}_{\text{Thermal noise}} + \underbrace{\frac{K_f}{f} \frac{g_m^2}{WLC_{ox}^2}\Delta f}_{\text{1/f noise}}$$

Useful References on MOSFET Noise

- **B. Wang et. al., “MOSFET Thermal Noise Modeling for Analog Integrated Circuits”, JSSC, July 1994**
- **Jung-Suk Goo, “High Frequency Noise in CMOS Low Noise Amplifiers”, PhD Thesis, Stanford University, August 2001**
 - <http://www-tcad.stanford.edu/tcad/pubs/theses/goo.pdf>
- **Jung-Suk Goo et. al., “The Equivalence of van der Ziel and BSIM4 Models in Modeling the Induced Gate Noise of MOSFETS”, IEDM 2000, 35.2.1-35.2.4**
- **Todd Sepke, “Investigation of Noise Sources in Scaled CMOS Field-Effect Transistors”, MS Thesis, MIT, June 2002**
 - <http://www-mtl.mit.edu/wpmu/sodini/theses/>

Input Referral of Noise



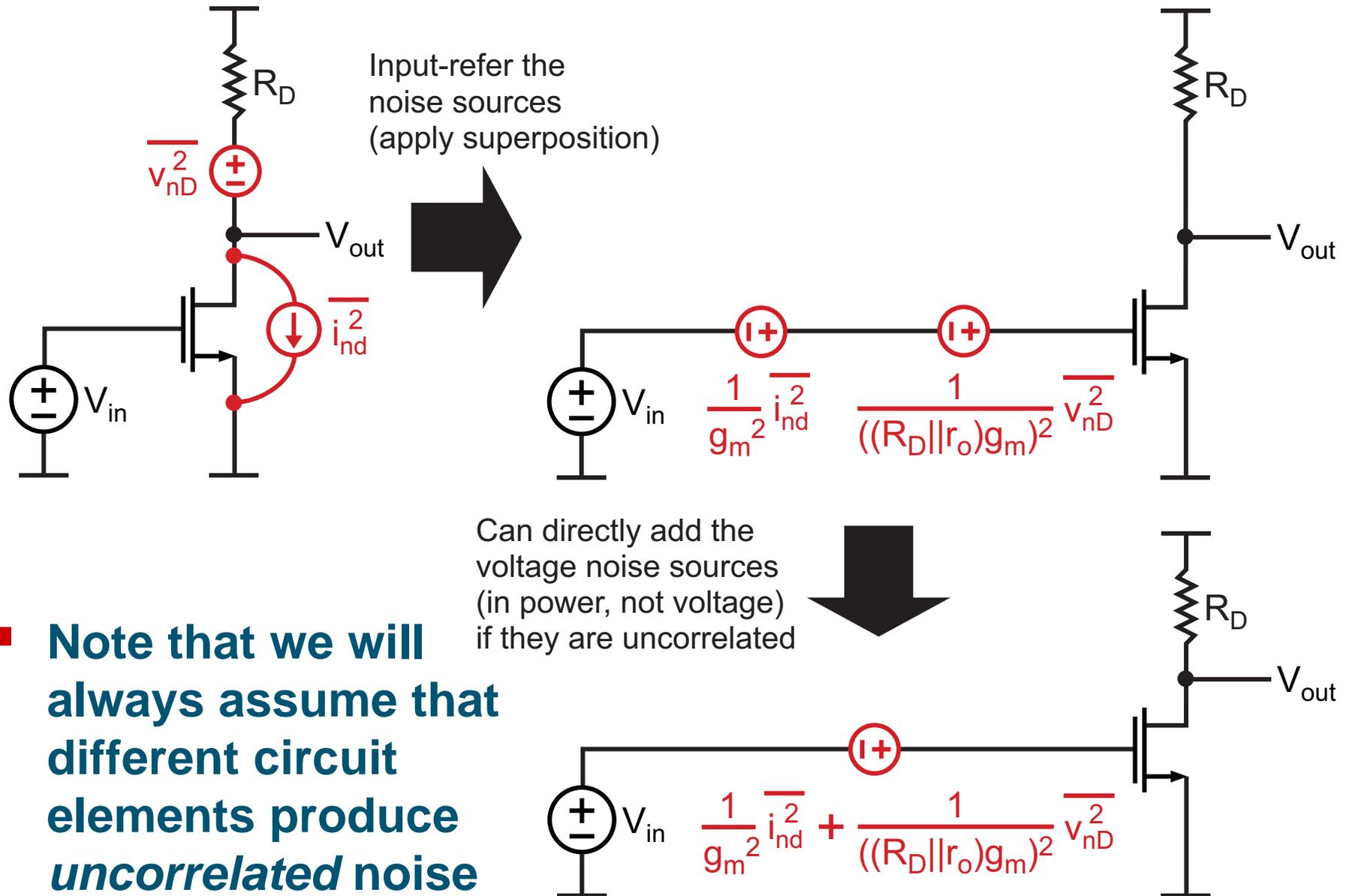
- It is often convenient to input refer the impact of noise when performing noise analysis in circuits
 - To justify the above, recall that filtering a random process $x(t)$ leads to an output random process $y(t)$ such that

$$S_y(f) = |H(f)|^2 S_x(f)$$

- For the case where $H(f) = K$ (i.e., a simple gain factor):

$$\Rightarrow S_y(f) = |K|^2 S_x(f) \Rightarrow S_x(f) = \frac{1}{|K|^2} S_y(f)$$

Example: Common Source Amplifier



- **Note that we will always assume that different circuit elements produce uncorrelated noise**

Summary

- Power spectral density provides a rigorous approach to describing the frequency domain behavior of the ensemble behavior of stationary, ergodic (zero mean) random processes
 - Key concepts: Expectation, Autocorrelation, Fourier Transform, Correlation, Filtering
- Circuit designers like the following “notation”
 - Single-sided rather than double-sided spectra
 - Voltage and current noise power denoted as $\overline{v_n^2}$ and $\overline{i_n^2}$
- Key noise properties of circuit elements
 - Resistor: thermal noise (white noise)
 - MOS transistor: thermal + 1/f noise
- Useful analysis tool: input referral of noise sources
 - Assumption of uncorrelated noise from different elements allows their power (i.e., variance) to be added